

# Characterization of ion-irradiation effects on third generation SiC fibers

J. Huguet-Garcia<sup>\*1</sup>, A. Jankowiak<sup>1</sup>, S. Miro<sup>2</sup>, R. Podor<sup>3</sup>, E. Meslin<sup>2</sup>, L. Thomé<sup>4</sup>, Y. Serruys<sup>2</sup>, and J. M. Costantini<sup>1</sup>

<sup>1</sup>CEA, DEN, Service de Recherches de Métallurgie Appliquées, F-91191 Gif-sur-Yvette, France.

<sup>2</sup>CEA, DEN, Service de Recherches de Métallurgie Physique, F-91191 Gif-sur-Yvette, France.

<sup>3</sup>ICSM-UMR5257 CEA/CNRS/UM2/ENSCM, Site de Marcoule Bat 426, BP17171, 30207 Bagnols sur Cèze, France.

<sup>4</sup>CSNSM, CNRS-IN2P3, Université Paris-sud, F-91405 Orsay, France.

\*Tel: +33169081211, Fax: +33169084613, Email: [juan.huguet-garcia@cea.fr](mailto:juan.huguet-garcia@cea.fr)

**Abstract** – *The objective of the present work is to study the irradiation effects on third generation SiC fibers which fulfill the minimum requisites for nuclear applications, i.e. Hi-Nicalon type S, hereafter HNS, and Tyranno SA3, hereafter TSA3. With this purpose, these fibers have been ion-irradiated with 4 MeV Au ions at RT and increasing fluences. Irradiation effects have been characterized in terms of micro-Raman Spectroscopy ( $\mu$ RS) and Transmission (TEM) and compared to the response of the as-irradiated model material, i.e. 6H-SiC single crystals. It is reported that ion-irradiation induces amorphization in SiC fibers. Ion-amorphization kinetics between these fibers and 6H-SiC single crystals are similar despite their different microstructures and polytypes with a critical amorphization dose of  $\sim 3 \times 10^{14} \text{ cm}^{-2}$  ( $\sim 0.6 \text{ dpa}$ ) at RT. Also, thermally annealing induced cracking is studied via in-situ Environmental Scanning Electron Microscopy (E-SEM). The temperatures at which the first cracks appear as well as the crack density growth rate increase with increasing heating rates. The activation energy of the cracking process yields 1.05 eV in agreement with recrystallization activation energies of ion-amorphized samples.*

## I. INTRODUCTION

Future nuclear applications include the deployment of the so-called Generation IV fission and fusion reactors, which are devised to operate at higher temperatures and to higher exposition doses than nowadays nuclear reactors. One of the critical issues to the success of future nuclear applications is to develop high performance structural materials with good thermal and radiation stability, neutron transparency and chemical compatibility.<sup>1</sup>

Structural materials for nuclear applications are exposed to high temperatures, aqueous corrosive environments and severe mechanical loadings while exposed to neutron and ion irradiation. Its exposure to incident energetic particles displaces numerous atoms from the lattice sites inducing material degradation. Such degradation is the main threat to the safe operation of core internal structures and is manifested in several forms: radiation hardening and embrittlement, phase instabilities from radiation-induced precipitation, irradiation creep and volumetric swelling.<sup>2</sup> As can be observed in Fig. 1, nominal temperatures and displacement doses can reach up to 1100 °C and 200 dpa depending on the nuclear reactor design. As a consequence, conventional nuclear materials,

mostly metallic alloys, do not meet the requirements to operate neither under nominal nor accidental conditions.

Nuclear grade Silicon Carbide based composites—fabrics made of third generation SiC fibers densified via CVI with a SiC matrix;  $\text{SiC}_f/\text{SiC}_m$ — are among the most promising structural materials for fission and fusion future nuclear applications.<sup>3</sup> However, several remaining uncertainties place  $\text{SiC}_f/\text{SiC}_m$  in a position that requires further research and development, notably the radiation behavior of the fiber reinforcement which is crucial for the composite radiation stability.

The objective of the present work is to study the irradiation effects on third generation SiC fibers which fulfill the minimum requisites for nuclear applications, i.e. Hi-Nicalon type S, hereafter HNS, and Tyranno SA3, hereafter TSA3. With this purpose, these fibers have been ion-irradiated under in-pile relevant conditions. The irradiation effects have been characterized in terms of micro-Raman Spectroscopy ( $\mu$ RS), Transmission (TEM) and Environmental Scanning Electron Microscopy (E-SEM) and compared to the response of the as-irradiated model material, i.e. 6H-SiC single crystals.

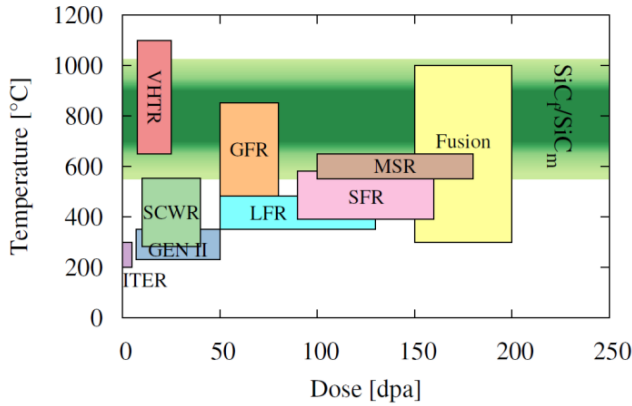


Fig. 1. Nominal operating temperatures and displacement doses for structural materials in different nuclear applications. The acronyms are defined in the nomenclature section. Green ribbon indicates the estimated temperature operation window for SiC<sub>f</sub>/SiC<sub>m</sub>. Adapted from Ref. <sup>2</sup>.

## II. MATERIALS AND METHODS

### II.A. 6H-SiC single crystals and third generation SiC fibers

6H-SiC single crystals of 246  $\mu\text{m}$  thickness were machined from N-doped (0001)-oriented 6H-SiC single crystal wafers grown by CREE Research using a modified Lely method. Crystals were of n-type with a net doping density ( $n_D - n_A$ ) of  $10^{17} \text{ cm}^{-3}$ . All samples were polished to achieve a microelectronics “epiready” quality.

Main characteristics of HNS and TSA3 fibers are summarized in Table I. Figure 2 shows TEM images of the microstructures of both fibers. Both fibers consist in highly faulted 3C-SiC grains and intergranular pockets of turbostratic C visible as white zones in Figure 2. SFs in SiC grains are clearly observed for both fibers as striped patterns inside the grains. Stacking fault (SF) linear density yields  $0.29 \pm 0.1 \text{ nm}^{-1}$  for HNS fibers and  $0.18 \pm 0.1 \text{ nm}^{-1}$  for TSA3 fibers. It has been determined by counting the number of stripes per unit length in the perpendicular direction using ImageJ<sup>4</sup> image analysis software. Also, mean maximum and minimum Feret diameters—which correspond to the shortest and the longest distances between any two points along the GB—were determined. These values yield, respectively, 26 and 36 nm for the HNS fibers and 141 and 210 nm for the TSA3 fibers.<sup>5</sup>

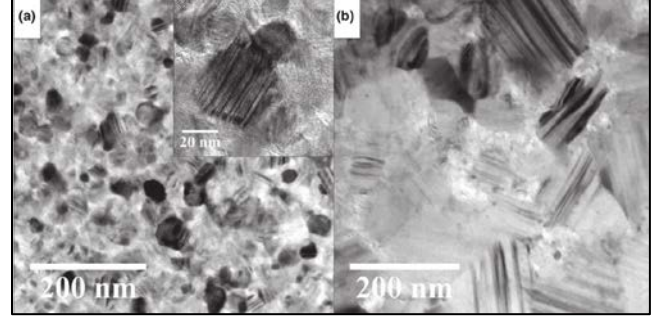


Fig. 2. TEM images of the as-received (a) HNS and (b) TSA3 fibers. Stripped patterns inside the grains indicate the high density of stacking faults in both samples. Reproduced from Ref.<sup>5</sup>

TABLE I

Main characteristics of third generation SiC fibers

Fiber	Tyranno SA3	Hi Nicalon type S
Producer <sup>6</sup>	Ube Industries	Nippon Carbon
Diameter ( $\mu\text{m}$ ) <sup>6</sup>	7.5	12
Density ( $\text{g cm}^{-3}$ ) <sup>6</sup>	3.1	3.05
C/Si ratio <sup>7,a</sup>	1.03–1.2	1.07
Composition <sup>6</sup>	68Si+32C+0.6Al	69Si+31C+0.2O
Grain Size (nm) <sup>5,b</sup>	141-210	26–36

a. Values correspond to the edge and core of the fiber respectively.  
b. Min. and max. Feret diameters.

### II.B. Ion-irradiation

Different 6H-SiC single crystals and SiC fibers were irradiated at room temperature (RT) with 4 MeV Au<sup>2+</sup> to  $5 \times 10^{12}$ ,  $10^{13}$ ,  $5 \times 10^{13}$ ,  $10^{14}$ ,  $2 \times 10^{14}$ ,  $3 \times 10^{14}$ ,  $10^{15} \text{ cm}^{-2}$  at JANNUS-Orsay facility and to  $2 \times 10^{15} \text{ cm}^{-2}$  at JANNUS-Saclay facility<sup>8</sup>. To evaluate the irradiation damage, ion-fluences have been converted to dpa with Eq. 1:

$$dpa = \frac{\frac{Vac}{ion \text{ \AA}} \times 10^8}{\rho_{SiC} [\text{atoms cm}^{-3}]} \times \varphi [\text{ions cm}^{-2}] \quad (1)$$

Where  $\varphi$  is the ion fluence,  $\rho_{SiC}$  the theoretical density of SiC ( $3.21 \text{ g cm}^{-3}$ ) and  $\frac{Vac}{ion \text{ \AA}}$  the vacancy per ion ratio given by SRIM-2010 calculations.<sup>9</sup> Figure 3 shows the vacancy per ion ratio and the implantation profiles as a function of the SiC depth. SRIM calculations have been performed with full damage cascades. Threshold displacement energies for C and Si sublattices were set to 20 and 35 eV respectively.<sup>10</sup>

### II.C. Micro-Raman Spectroscopy ( $\mu\text{RS}$ )

Irradiated samples were characterized at JANNUS-Saclay facility by surface  $\mu\text{RS}$  at RT using an Invia Reflex Renishaw (Renishaw plc, Gloucestershire, UK) spectrometer. The 532 nm line of a frequency-doubled Nd-YAG laser was focused on a  $0.5 \mu\text{m}^2$  spot and collected through a 100 $\times$  objective. The laser output power was kept around 2 mW to avoid sample heating.

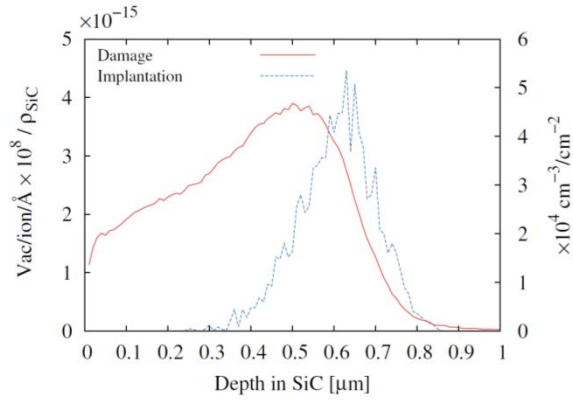


Fig. 3. Damage and implantation profiles for 4 MeV Au in SiC. Fluence-dpa estimation can be obtained by direct multiplication of the y axis per the ion fluence.

#### *II.D. Transmission (TEM) and Environmental Scanning Electron Microscopy (E-SEM)*

Thin foils for TEM observations were prepared using the Focused Ion Beam (FIB) technique. The specimens were extracted from the samples irradiated to  $2 \times 10^{15} \text{ cm}^{-2}$  using a Helios Nanolab 650 (FEI Co., Hillsboro, OR, USA) equipped with electron and Ga ion beams. The specimen preparation procedure is described elsewhere.<sup>5</sup> TEM observations were conducted in a conventional CM20 TWIN-FEI (Philips, Amsterdam, Netherlands) operated at 200 kV equipped with a LaB6 crystal as electron source and a Gatan (Gatan Inc, Warrendale, PA, USA) heating specimen holder (25–1000 °C) with manual temperature control. The CCD camera used to take pictures is a Gatan Orius 200.

The E-SEM observation was conducted in a FEI QUANTA 200 ESEM FEG equipped with a heating plate (25–1500 °C), operated at 30 kV. Precise sample temperature measurement is ensured by a homemade sample holder containing a Pt-Pt-Rh10 thermocouple<sup>11</sup> H<sub>2</sub>O pressure was kept constant at 120 Pa. The 6H-SiC samples were quickly heated up to 900 °C to then set the heating rate to values ranging from 1 to 30 °C/min for each test.

### III. RESULTS AND DISCUSSION

#### *III.A. Third generation SiC fibers microstructure and Raman spectra*

$\mu$ RS is a powerful characterization technique based on the inelastic scattering of light due to its interaction with the material atomic bonds and the electron cloud providing a chemical fingerprint of the analyzed material. SiC is known to have numerous stable stoichiometric solid crystalline phases, so-called polytypes, being the cubic (3C-SiC) and the hexagonal (6H-SiC) the most common

ones.<sup>12</sup> Raman peak parameters such as intensity, bandwidth and wavenumber provide useful information related to the phase distribution and chemical bonding of SiC and SiC fibers.<sup>13</sup> Table II gathers the characteristic Raman peak wavenumber for 3C- and 6H-SiC polytypes.

Figure 4 shows the collected Raman spectra for the as-received samples. For the 6H-SiC spectrum, group-theoretical analysis indicates that the Raman-active modes of the wurtzite structure ( $C_{6v}$  symmetry for hexagonal polytypes) are the A1, E1 and E2 modes. In turn, A1 and E1 phonon modes are split into longitudinal (LO) and transverse (TO) optical modes. Also, the high quality of the sample allows the observation of second order Raman bands as several weaker peaks located at 500  $\text{cm}^{-1}$  and between 1400–1850  $\text{cm}^{-1}$ .

Raman spectra collected from as-received TSA3 and HNS fibers differ notably from the single crystal one. Their polycrystalline microstructure and the intergranular free C showed in Figure 2 induce the apparition of several peaks related to their chemical fingerprint. Peaks located between the 700  $\text{cm}^{-1}$  and 1000  $\text{cm}^{-1}$  are related to the cubic SiC polytype. Satellite peaks around 766  $\text{cm}^{-1}$  are attributed to disordered SiC consisting of a combination of simple polytype domains and nearly periodically distributed stacking faults<sup>13, 14</sup>. This explanation is consistent with the high SF density observed in Figure 2.

High-intensity peaks located between 1200  $\text{cm}^{-1}$  and 1800  $\text{cm}^{-1}$  are attributed to the intergranular free C despite the little free C content of both fibers. The high contribution of these peaks to the spectra is due to the high Raman cross-section of C-C bonds which is up to ten times higher than the Si-C bonds one.<sup>15</sup> Regarding the C chemical fingerprint, G peak centered around 1581  $\text{cm}^{-1}$  is related to graphitic structures as a result of the  $sp^2$  stretching modes of C bonds and the D peak centered around 1331  $\text{cm}^{-1}$ , according to Colomban et al.<sup>13</sup> should be attributed to vibrations involving  $sp^3$ - $sp^{2/3}$  bonds. Finally, the shouldering appearing on the G band in both fibers, D', results from the folding of the graphite dispersion branch corresponding to G at  $\Gamma$  point.

TABLE II

Raman shift for 3C- and 6H-SiC<sup>16</sup>

Polytype	X=q/qB	Raman shift [ $\text{cm}^{-1}$ ]			
		Planar acoustic	Planar optic	Axial acoustic	Axial optic
		TA	TO	LA	LO
3C-SiC	0	-	796	-	972
	0	-	797	-	965
6H-SiC	2/6	145,150	789	-	-
	4/6	236,241	-	504,514	889
	6/6	266	767	-	-

There is a remarkable difference in the G peak intensity between TSA3 and HNS fibers. It has been stated that the G over D peak intensity ratio is proportional to the in-plane graphitic crystallite size.<sup>17</sup> Therefore, the smaller size of the intergranular free C pockets of HNS takes account for such difference.

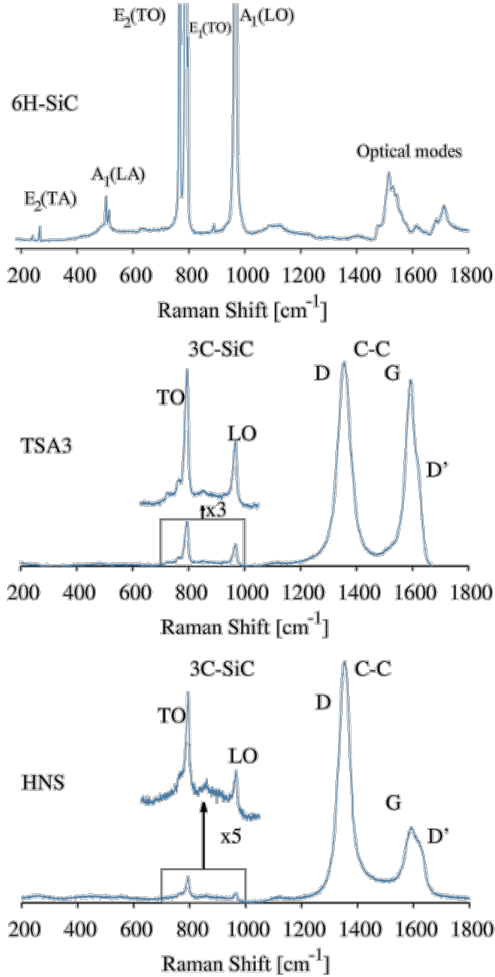


Fig. 4. Surface Raman spectra for as-received 6H-SiC single crystal and third generation SiC fibers. Adapted from Ref. <sup>5</sup>

### III.B. Ion-irradiation induced amorphization

Under in-pile conditions, SiC composites will be subjected to neutron and ion irradiation. When an energetic incident particle elastically interacts with a lattice atom there is a kinetic energy exchange between them. If this transmitted energy is higher than the threshold displacement energy of the knocked lattice atom it will be ejected from its equilibrium position giving birth to a Frenkel pair: a vacancy and an interstitial atom. In turn, if the kinetic energy transfer is high enough, the displaced atom may have enough kinetic energy to displace not only one but many atoms of the lattice, which, in turn, will

cause other displacement processes giving birth to displacement cascade. The number of surviving defects after the thermal recombination of the displacement cascade may pile up dealing to the degradation of the exposed material.<sup>18</sup>

Ion-irradiation has been widely used by the nuclear materials community to simulate neutron damage due to the tunability of the radiation parameters (dose, dose rate, temperature) and the similarity of the defect production in terms of displacement cascade creation.<sup>19</sup>

In this work, the samples have been irradiated to increasing fluences at RT with 4 MeV Au ions in order to simulate neutron damage. Figure 5 shows the evolution of the Raman spectra as a function of the irradiation dose. As can be observed, ion-irradiation induces sequential broadening of the Si-C bond related peaks until they combination in a unique low-intensity broad peak. Also, ion-irradiation induces the appearance of new low-intensity broad peaks at  $\sim 500$   $\text{cm}^{-1}$  and  $\sim 1400$   $\text{cm}^{-1}$ . These changes in the Raman spectra imply a significant modification of the local structure and correspond respectively to the dissociation of the Si-C bonds and the creation of Si-Si and C-C homonuclear bonds.<sup>20</sup> It is wise to highlight that in SiC fibers irradiation at low doses increases the intensity of the Si-C related peak despite its randomization. As commented, there is a remarkable influence of the free C in the SiC fibers Raman spectra due to the high Raman cross-section of C-C bonds. Under irradiation, the rupture of these bonds will imply the drop of its cross-section allowing the SiC Raman signal to emerge over the free C one. Finally, the spectra show similar low-intensity broad peaks at  $\sim 800$   $\text{cm}^{-1}$  characteristic of amorphous SiC. As can be observed in Figure 6, complete amorphization of the ion-irradiated layer is confirmed by TEM imaging and electron diffraction of samples irradiated to 4 dpa ( $2 \times 10^{15}$   $\text{cm}^{-1}$ ). SAED patterns of these zones are composed of diffuse concentric rings.

Ion-amorphization kinetics for 6H-SiC single crystals has been previously studied by  $\mu$ RS in terms of the total disorder parameter and the chemical disorder. The former is defined as  $(1 - A/A_{\text{cryst}})$  corresponding to the total area A under the principal first-order lines normalized to the value  $A_{\text{cryst}}$  of the crystalline material. The latter is defined as the ratio of C-C homonuclear bonds to Si-C bonds and denoted as  $\chi_{(\text{C-C})}$ , ranging from zero for perfect short-range order to unity for random short-range disorder. Short-range order describes the degree of the chemical state with respect to the local arrangement of atoms, which can be partially preserved even when the LRO is completely lost.<sup>20, 21</sup>

In our work, the use of these parameters to study the ion-amorphization of SiC fibers is limited by two factors. First, the Si-C signal increases at low doses, hence invalidating  $A/A_{\text{norm}}$  as an indicative of the total disorder evolution, and second, the enormous impact of the free C

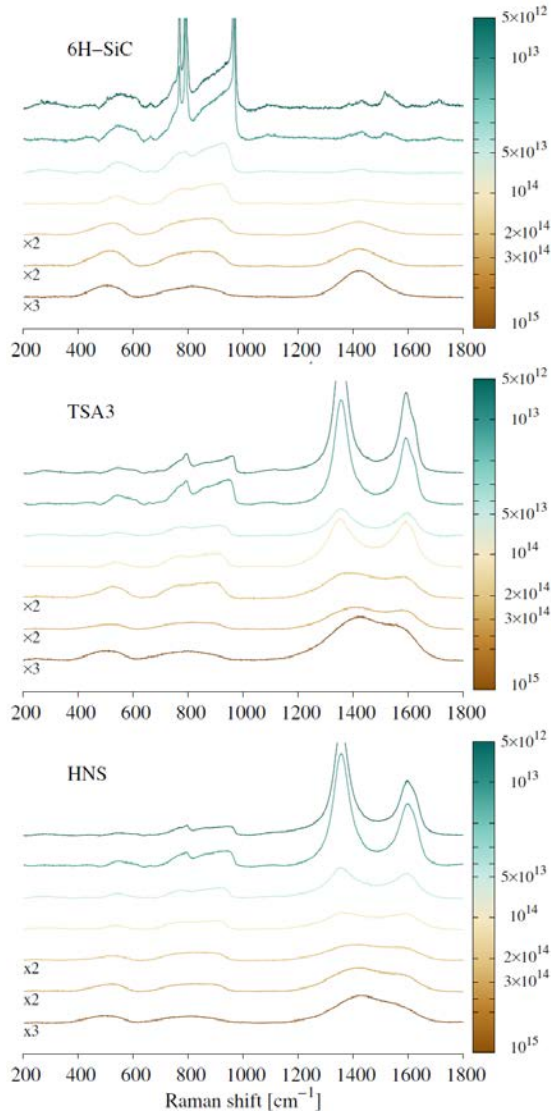


Fig. 5. Surface Raman spectra for ion-irradiated 6H-SiC single crystal and third generation SiC fibers.

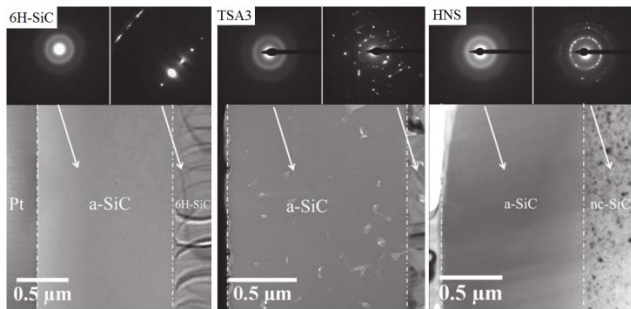


Fig. 6. TEM images and SAED patterns obtained from the irradiated 6H-SiC and SiC fibers with 4 MeV Au<sup>3+</sup> ions at RT to  $2 \times 10^{15} \text{ cm}^{-2}$ . The concentric and diffuse rings in SAED patterns indicate that the irradiated layer is completely amorphous (a-SiC). nc-SiC stands for nano-crystalline SiC. Adapted from Ref. <sup>5</sup>.

of the as-received fibers in their Raman spectra, hence invalidating  $\chi_{(C-C)}$  as a good indicative of the short-range order evolution. In order to overcome these limitations, chemical disorder has been calculated as the ratio of Si-Si homonuclear bonds to Si-C bonds ( $\chi_{(Si-Si)}$ ) which can be under the assumption that the intensity of the Raman peaks is proportional to the concentration of the related atomic bond.<sup>20</sup>

Figure 7 shows the  $\chi_{(Si-Si)}$  evolution as a function of the dose for the three samples. Data has been fitted with a multistep damage accumulation (MSDA) model given by Eq. 2:

$$f_d = \sum_{i=1}^n [(f_{d,i}^{sat} - f_{d,i-1}^{sat})(1 - e^{-\sigma_i(\varphi - \varphi_{i-1})})] \quad (2)$$

Where n is the number of steps in damage accumulation,  $f_{d,i}^{sat}$  the level of damage saturation for the step i,  $\sigma_i$  the damage cross section for the step i, and  $\varphi$  and  $\varphi_{i-1}$  the dose and the saturation dose of the i<sup>th</sup> step.<sup>22</sup>

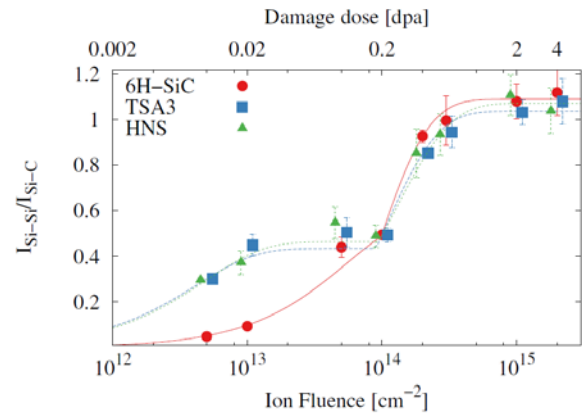


Fig. 7. Intensity of the Raman peaks associated to homonuclear Si-Si bonds normalized to the intensity of the Raman peaks associated to Si-C bonds. Experimental data is horizontally offset for the sake of clarity and fitted with the MSDA model (n=2) presented in Eq. 2.

TABLE III

Best-fit MSDA parameters for n=2 (two-step) of the  $\chi_{(Si-Si)}$  evolution with dose.

Sample	n=2			
	i=1		i=2	
	$f_d^{sat}$	$\sigma_1^a$	$f_d^{sat}$	$\sigma_2^a$
6HSiC	0.58	0.54	1.09	0.82
TSA3	0.45	0.046	1.03	0.94
HNS	0.46	0.049	1.07	1.18

a. Cross-sections in  $\times 10^{-14} \text{ cm}^2$  units.

MSDA model assumes that damage accumulation is a sequence of distinct transformations of the current structure of the irradiated material and that reduces to a direct impact (DI) model meaning that amorphization is achieved in a single cascade.<sup>22</sup> Table III gathers the best-fit (non-linear least-squares Marquardt-Levenberg algorithm) parameters for  $n=2$  of the  $\chi_{(Si-Si)}$  evolution with dose.

MSDA parameters for 6H-SiC amorphization kinetics are consistent with previous reported ones based in RBS and  $\mu$ RS data<sup>21, 23</sup> hence confirming  $\chi_{(Si-Si)}$  as a relevant indicative for the amorphization level of the sample.

According to the MSDA parameters, there is a significant difference in the first stage of the amorphization process between SiC fibers and 6H-SiC. However, this difference may arise from the difficulty to treat the Raman spectra of SiC fibers due to their C signal so it cannot be directly attributed to a prompt amorphization. More experimental data is needed to confirm this hypothesis.

In other hand, all irradiated samples show an inflexion point around  $10^{14} \text{ cm}^{-2}$  (0.2 dpa) and reach the saturation value over  $3 \times 10^{14} \text{ cm}^{-2}$  (0.6 dpa). Therefore, it can be asserted that there is no significant difference in the ion-amorphization kinetics of the three samples regardless their different polytype, composition and microstructure.

It is widely accepted that GBs act as point defect sinks.<sup>24</sup> However, the grain size must be optimized because a small grain size has two opposing effects on the free energy of an irradiated material. For instance, a smaller grain size hinders intragranular point defects accumulation which, in turn, decreases the free energy resulting from irradiation-induced defects. However, a smaller grain size also may increase the free energy resulting from the increase on the GB density which can favor the path toward an amorphous phase.<sup>25</sup> The microstructure influence of the behavior of SiC under irradiation is controversial as both experimental and computational studies can be found concerning whether if grain refinement enhances or reduces SiC radiation resistance.<sup>26–29</sup> The similar ion-amorphization kinetics of 6H-SiC, TSA3 and HNS suggest that the microstructure of these fibers is not refined enough to show significant enhanced or reduced radiation resistance—not even for the HNS fibers which grain sizes are around 20 nm.

### III.C. *In-situ* E-SEM thermal annealing

Radiation induced amorphization causes the degradation of the material's physico-chemical properties.<sup>30</sup> However, irradiation induced damage in SiC can be recovered by thermal annealing at high temperatures<sup>21, 31</sup>. On the other hand, it has been also reported that thermal annealing has an undesirable side effect. As shown in Figure 8, it induces mechanical failure of the completely ion-amorphized layers in single crystals<sup>21, 32</sup> and more recently in HNS fibers.<sup>33</sup> Also, it has been reported that mechanical failure of the annealed

samples is not due to thermal effects and recrystallization has been pointed out as the underlying mechanism.<sup>33</sup>

In order to study the mechanical failure phenomenon, several thermal annealing tests at different temperature ramps of ion-amorphized 6H-SiC single crystals have been conducted and observed via *in-situ* E-SEM.

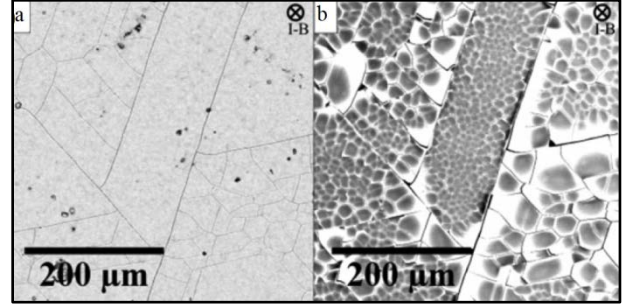


Fig. 8. Mechanical failure evolution of the SiC ion-amorphized layer during thermal annealing: (a) Cracks appear along the cleavage planes and eventually lead to (b) exfoliation. Adapted from Ref. <sup>33</sup>.

Figure 9 shows the evolution of the linear crack density as a function of the temperature of the sample for different heating ratios. As it can be observed, crack density reaches similar saturation values independently of the heating rate whereas cracking kinetics are heating rate dependent. For instance, both the temperatures at which the first crack appears and the crack density growth rate increase with increasing heating rates.

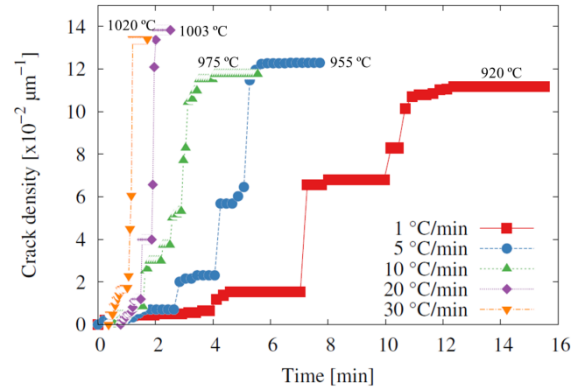


Fig. 9. Crack density evolution during the *in-situ* thermal annealing for different temperature ramps. Values near the curves refer to the temperature at which the first crack was observed during the respective test.

In order to characterize the cracking kinetics, the experimental data have been assumed to obey an Arrhenius equation as it's a thermal activated phenomenon in order to obtain the characteristic activation energy ( $E_a$ ) of the process. Figure 10 shows the log-plot of two characteristic features of the cracking phenomenon: the inverse of the time necessary to reach the 50% of the cracking density

( $t_{50\%}$ ) as a function of the inverse of the sample temperature at time  $t_{50\%}$ , denoted as  $T_{50\%}$ . These two parameters have been successfully applied for the study of the recrystallization temperature of tungsten as a function of the heating rate and allow to get rid of the time dependency of the test.<sup>34</sup> Linear fit to the log-plot yields an  $E_a$  of 1.05 eV. This value falls in the range of recrystallization activation energies found by isothermal annealing of ion-amorphized SiC, i.e. 0.36-0.65<sup>21</sup> to 2.1<sup>32</sup> eV, sustaining the recrystallization phenomenon as the underlying mechanism inducing mechanical failure.

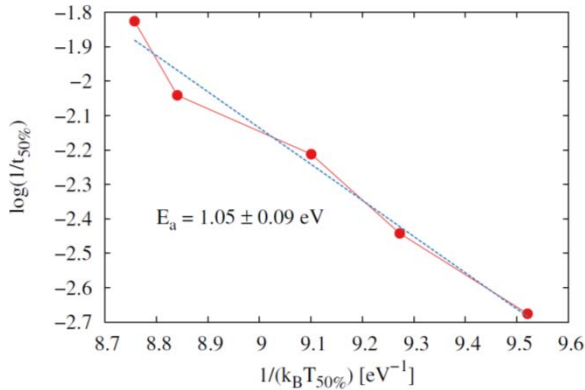


Fig. 10. Log-plot of the inverse of the time necessary to reach the 50% of the cracking density ( $t_{50\%}$ ) as a function of the inverse of temperature at this moment ( $T_{50\%}$ ).  $E_a$  is the activation energy for the cracking phenomenon.

#### IV. CONCLUSIONS

In this work, ion-amorphization of SiC fibers has been studied in terms of surface  $\mu$ RS and TEM imaging and compared to the model material, i.e. 6H-SiC. It is reported that there are no significant differences between the ion-amorphization kinetics of SiC fibers and 6H-SiC fibers despite their different SiC polytypes and microstructures. Critical amorphization dose yields  $\sim 3 \times 10^{14}$  cm<sup>-2</sup> ( $\sim 0.6$  dpa) for 4 MeV Au ions at RT.

Also, the kinetics of thermally annealing induced cracking is studied via *in-situ* E-SEM observations. It is reported that the temperatures at which the first cracks appear as well as the pace of crack density growth increase with increasing heating rates. The activation energy of the cracking process yields 1.05 eV in agreement with recrystallization activation energies of ion-amorphized samples. This observation supports recrystallization as the underlying mechanism for the mechanical failure of the annealed samples.

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#### NOMENCLATURE

$\mu$ RS: micro-Raman Spectroscopy  
 dpa: displacements per atom  
 DTA: Dose To Amorphization  
 E-SEM: Environmental Scanning Electron Microscope  
 GENII: Generation II (current nuclear reactors)  
 GFR: Gas Fast Reactor  
 HNS: Hi-Nicalon type S  
 LFR: Lead Fast Reactor  
 MSDA: Multistep Damage Accumulation  
 MSR: Molten Salt Reactor  
 RBS: Rutherford Backscattering Spectrometry  
 SAED: Selected Area Electron Diffraction  
 SCWR: Super Critical Water Reactor  
 SFR: Sodium Fast Reactor  
 TEM: Transmission Electron Microscope  
 TSA3: Tyranno SA3  
 VHTR: Very High Temperature Reactor

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